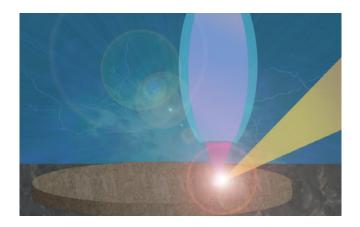
Axially symmetric mirror lens

Breakthrough high-resolution synchrotron focusing and collimating x-ray optics



Designed to replace KB Mirrors, ZPs, and Polycapillaries for microfocus beamlines

How will Sigray improve your beamline performance?

| Energy | Applications | Sigray advantage over other approaches | | |
|------------|----------------------------|--|--|--|
| <3 keV | Ptychography (0.2 - 3 keV) | High NA & efficiency for soft x-rays, larger working distance than zoneplates, and | | |
| | ARPES (0.5 - 2 keV) | | | |
| | PEEM (0.1 - 3 keV) | achromatic | | |
| <20 keV | TXM (0.3 - 20 keV) | Customer-specific design, achromatic, high efficiency | | |
| 2 - 60 keV | μXRF (2 - 30 keV) | High flux, high efficiency, | | |
| | μXRD (5 - 60 keV) | and shorter working distanc- es than KB mirrors | | |
| | XAFS (2 - 20 keV) | os man no minors | | |
| | Super Confocal ** | ** Super confocal options available upon request for <5 µm (configuration uses a twin paraboloidal lens scheme with multiple advantages over polycapillary optics) | | |

Focal size and working distance

The focus size is dependent on working distance (optic to sample). Currently achievable spot sizes are down to 0.2 µm (see table on right), and continuous improvements in reducing focus size are ongoing.

| Focus (FWHM) as a function of working distance | | | | | |
|--|-----|-----|-----|-----|-----|
| Working distance (mm) | 2 | 5 | 10 | 20 | 30 |
| Focus (µm) | 0.2 | 0.4 | 0.6 | 0.8 | 1.5 |

Sigray's axially symmetric mirror lenses provide:

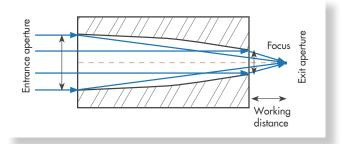
- High resolution (0.2 2 µm)
- Large NA for higher flux
- Energies from 0.1 to 60 keV
- Transmission efficiency >80%
- Working distance 1-100 mm

Features

- Superior performance for your beamline
- Axial symmetry and advanced, customized manufacturing
- Optimized designs for your needs

Sigray offers paraboloidal (see figure), ellipsoidal, and toroidal optics for high resolution focusing or low divergence collimation. the parameters and shape of the axially symmetric mirror lens can be customized upon request.

Example specifications of a focusing paraboloidal mirror lens optimized for 9 keV are shown below. note that optics are available for 0.1 to 60 keV, with parameters dependent on energy of interest.



Paraboloidal mirror lens configured to focus x-rays

| Parameter | Specification |
|--|--|
| Critical energy at max convergence angle | 9 keV (up to 15 keV x-rays can be focused with lower efficiency) |
| Minimum focus | 0.8 µm |
| Reflecting surface | Coated with Platinum (other materials available upon request) |
| Working distance (mm) | 20 mm |
| Convergence angle (2x numerical aperture) | 35 mrad |
| Entrance aperture (id) exit aperture (od) | 1.4 mm 0.7 mm |
| Strehl ratio | 75% (larger value can be achieved upon request) |
| Transmission efficiency | ~90% |





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Breakthrough X-ray optic advantages

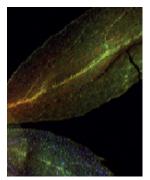
The choice of x-ray optics for high resolution, microns-scale imaging has typically been limited to Kirkpatrick-Baez (KB) mirrors or zoneplates (ZP).

| Advantages over KB mirrors | | | |
|---------------------------------|---|--|--|
| Advantage | Technical parameters and details | | |
| Higher numerical aper- | >2x the numerical aperture for | | |
| ture and flux | >4x the flux of a KB mirror | | |
| Improved beamline design | Short working distances for large de- magnification of the source (allows short- er, more cost-effective beamline develop- ment) and no off-axis beam deflection | | |
| | Allows multiple lenses within a single beamline (see right) | | |
| Soft X-ray capabilities | Single reflection provides improved performance for low energy x-rays | | |
| Flexible Experimental Design | Compact and lightweight form factor enables scanning of the x-ray optic (instead of the sample) and easier alignment | | |

| Advantages over zoneplates | | | |
|---|--|--|--|
| Advantage | Technical parameters and details | | |
| Substantially larger numerical aperture | Equivalent to a 4 nm zoneplate | | |
| Achromatic | Simplifies many microbeam applications and is essential for spectroscopy | | |
| Higher flux & efficiency | >100x flux due to high efficiency & larger numerical aperture | | |

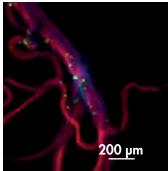


Multiple mirror lenses can be used in a single beamline to optimize for different applications. Shown is an optional tip-tilt stage available for purchase, with each optic designed with different parameters (e.g. energy, convergence angle, spot size, working distance, etc).









MicroXRF mapping of a hyper accumulating seedling using common laboratory source with double paraboloidal optic. Elemental overlay map relating the distribution of three selected elements of interest (K, Cl, S) and rol scan of trace elemental (Mn, ni) accumulation in the seedling roots.

Samples provided by Dr. Antony van der Ent and Dr. Peter Erskine, The University of Queensland, Australia



